

# Layer Growth of high-quality BaSO<sub>4</sub>:Mn<sup>6+</sup> using Liquid Phase Epitaxy

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Single-crystalline host materials doped with transition-metal ions are of high interest for applications as tunable lasers. Mn<sup>6+</sup> ions exhibit broadband luminescence, however, Mn<sup>6+</sup>-doped crystals or waveguide structures could as yet not be grown in sufficient quality. The active material has to be free of inclusions or defects larger than  $\lambda/10$ , with  $\lambda$ , the wavelength of the propagating beam. The interface between active layer and substrate must be optically flat to receive low-loss guiding properties. Finally, in the case of homoepitaxy of BaSO<sub>4</sub>, the doped layer has to be arranged on the substrate (001) direction.

The growth temperature of BaSO<sub>4</sub>:Mn<sup>6+</sup> is limited by the decomposition of BaSO<sub>4</sub> at 1590°C, its phase transition above 1010°C, and especially the chemical reduction of the manganese dopant from Mn<sup>6+</sup> to Mn<sup>5+</sup> above 620°C. Therefore, the growth of BaSO<sub>4</sub>:Mn<sup>6+</sup> from a solution at lower temperatures is the most suitable method. Liquid phase growth is close to the thermodynamic equilibrium and has enabled us to grow high-quality layers.

First, we prepared undoped BaSO<sub>4</sub> crystals of 10 x 5 x 1 mm<sup>3</sup> in a, b, and c-direction, respectively, using the flux method with LiCl as solvent. Subsequently, growth of high-quality undoped BaSO<sub>4</sub> was performed by liquid phase epitaxy (LPE), using the additive ternary CsCl-KCl-NaCl solution. We obtained crystalline layers free of inclusions, grown in the Frank-Van der Merwe mode (layer-by-layer growth). Finally, layers of BaSO<sub>4</sub>:Mn<sup>6+</sup> were fabricated with thicknesses up to 150  $\mu\text{m}$ , at growth rates of 3  $\mu\text{m}/\text{h}$  and temperatures of 500–580°C. The thickness was controllable with a precision of  $\pm 0.1 \mu\text{m}$ . The Mn<sup>6+</sup> concentration in the doped layer was up to 1 mol.% with respect to S<sup>6+</sup>.

In collaboration with the University of Hamburg, absorption and emission spectra were measured, which confirmed that the manganese ion was incorporated in the layer solely in its sextavalent oxidation state. Room-temperature luminescence in the wavelength range 850–1600 nm was observed.